



Pokhara University
Everest Engineering College
Final Assessment I
Fall - 2020

Level: Bachelor F.M. 100
 Program: BE(Cmp) P.M. 45
 Faculty: Science & Technology Time:3hrs
Subject: Electrical Engineering Materials (3rd Semester)

Attempt all the questions.

1	a) Write down the physical significance of wave function ψ . Derive the time dependent Schrödinger wave equation.	9
	b) If electrical conductivity of Potassium is 1.39×10^5 Sm/cm. Calculate the drift mobility of electron at room temperature. Molar mass and density of potassium are 39.95 and 0.91 gm/cc.	6
2	a) Derive the relation for effective mass of an electron ,also give the significance of effective mass of electron.	8
	b) How conduction takes place in gases? Explain briefly on the basis of Townsend's break down mechanism.	7
3	a) What are different types of polarization in dielectric medium? Explain orientational polarization in detail.	8
	b) The crystal of sodium chloride has state dielectric constant of 5.6 and optical index of refraction 1.5. Calculate the percentage contribution of ionic polarizability.	7
4	a) What are ferromagnetic materials? With the help of hysteresis loop, classify hard and soft magnetic material?	9
	b) Calculate the relative permeability of a paramagnetic material at -73°C and 227°C if the susceptibility of the paramagnetic material at 27°C is 3.7×10^{-3} .	6

5	<p>a) Starting from Fermi-Dirac distribution function prove that the Fermi level in intrinsic semiconductor lies midway between the conduction band and valence band.</p> <p>b) In an abrupt Si p⁺n junction, the mobility for minority electrons and holes are 120 cm²- V⁻¹ S⁻¹ and 440 cm² V⁻¹S⁻¹ at T = 300 K. The life time of holes in n-region is 417nS, where as that of electrons in the p-region is 5nS. Calculate the diffusion coefficients and minority carrier diffusion lengths.</p>	<p>8</p> <p>7</p>
6	<p>a) Explain how pn-junction is formed when n - type and p - type semiconductor are brought together. Derive the relation of built in potential of a pn junction.</p> <p>b) Find the resistance of a 1cm³ pure Silicon crystal. What is the resistance when the crystal is doped with one Arsenic in 10⁹ Silicon atoms? Given: Atomic concentration is Si is 5 × 10²² cm⁻³, n_i = 1.45 × 10¹⁰ cm⁻³, μ_e = 1350 cm² V⁻¹ S⁻¹ and μ_h = 450 cm²V⁻¹S⁻¹.</p>	<p>9</p> <p>6</p>
7	<p>Write short notes on: (Any two)</p> <p>a) Face Centered Cubic Lattice</p> <p>b) Schottky Effect</p> <p>c) Epitaxial growth</p>	<p>2*</p> <p>5=</p> <p>10</p>

Best of Luck